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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Hisao IGARASHI, et al.

SERIAL NO.: NEW U.S. PCT APPLICATION

FILED: HEREWITH

INTERNATIONAL APPLICATION NO.: PCT/JP05/06108

INTERNATIONAL FILING DATE: March 30, 2005

FOR: PROBE APPARATUS, WAFER INSPECTING APPARATUS PROVIDED WITH THE

PROBE APPARATUS AND WAFER INSPECTING METHOD

## REQUEST FOR PRIORITY UNDER 35 U.S.C. 119 AND THE INTERNATIONAL CONVENTION

Commissioner for Patents Alexandria, Virginia 22313

In the matter of the above-identified application for patent, notice is hereby given that Sir: the applicant claims as priority:

COUNTRY Japan

APPLICATION NO 2004-102948

DAY/MONTH/YEAR 31 March 2004

Certified copies of the corresponding Convention application(s) were submitted to the International Bureau in PCT Application No. PCT/JP05/06108. Receipt of the certified copy(s) by the International Bureau in a timely manner under PCT Rule 17.1(a) has been acknowledged as evidenced by the attached PCT/IB/304.

> Respectfully submitted, OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C.

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